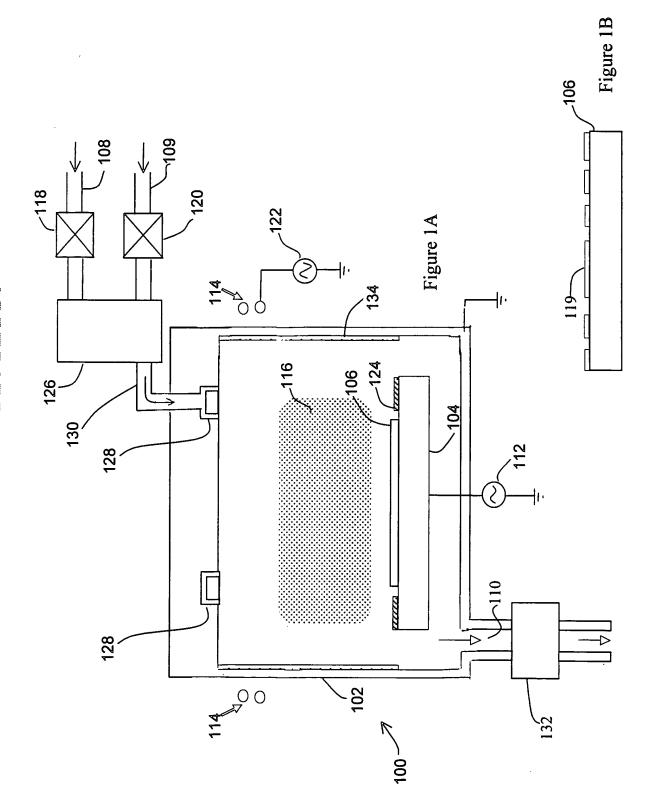
No.: Not Yet Assigned
Applicant(s): Y. Long He, et al.
PLASMA ETCHING UNIFORMITY CONTROL





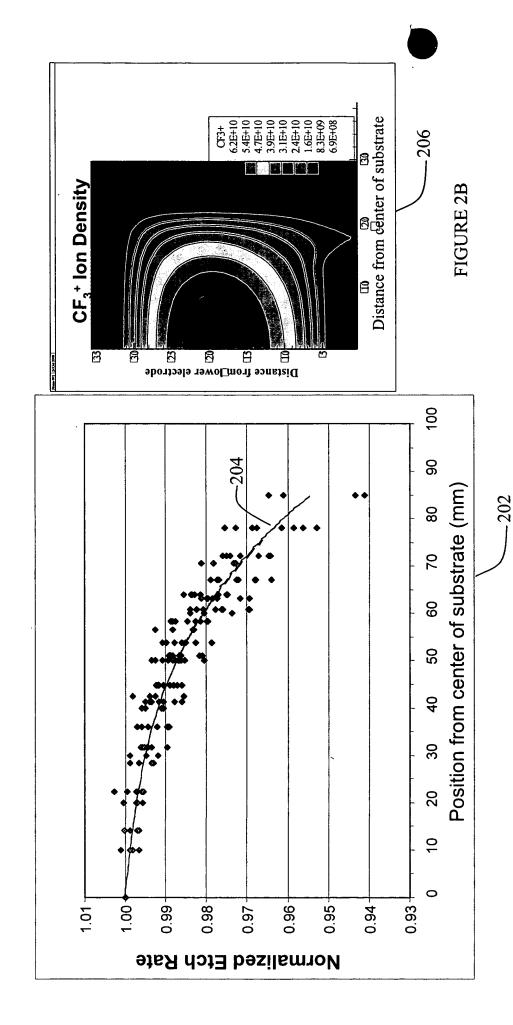


FIGURE 2A

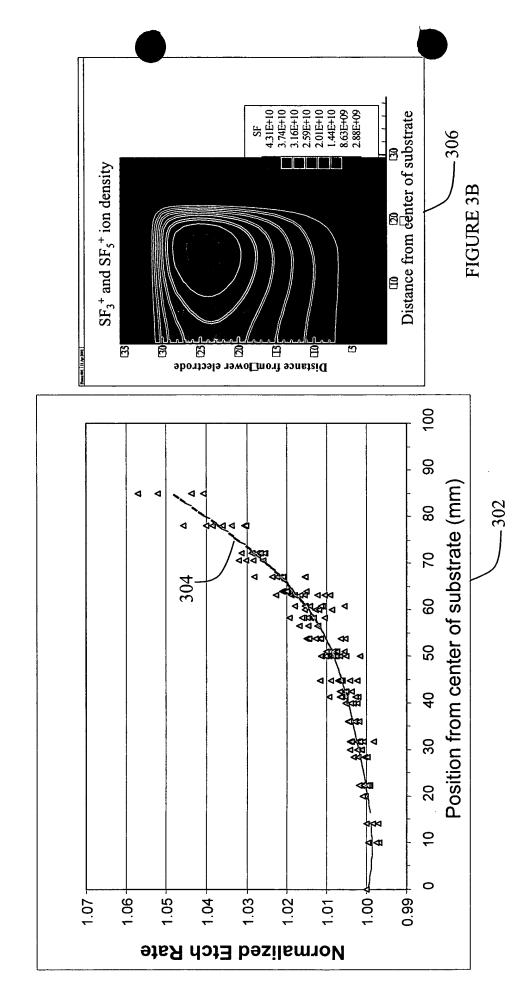
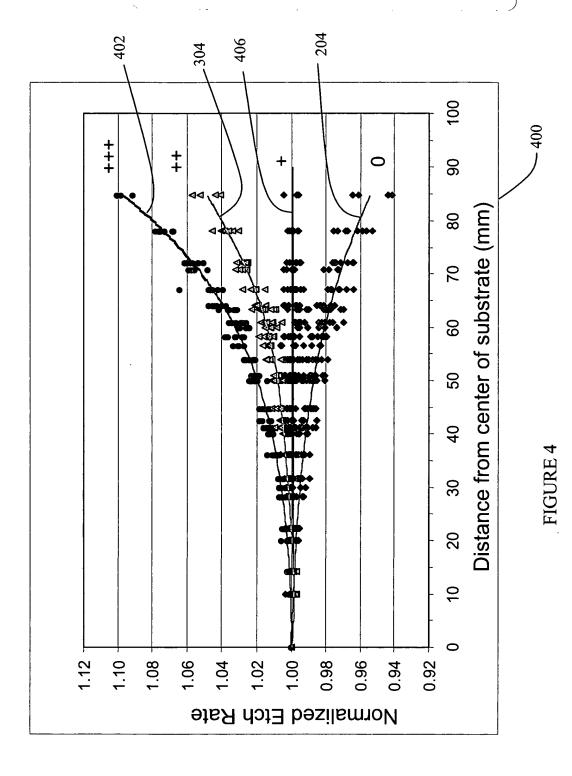
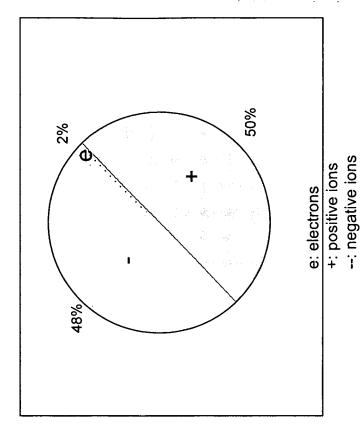
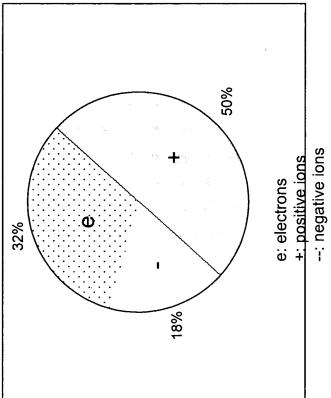


FIGURE 3A







**FIGURE 5A** 

FIGURE 5B

